

Aluminium **SILICON** Sputtering Target

NS6130-10-1028

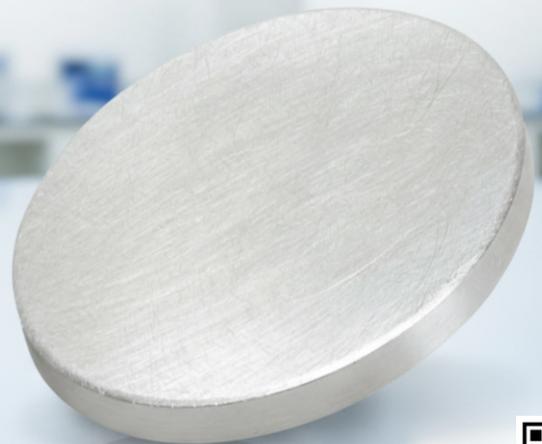
Quick Facts

| | | |
|-------------------|---|-------------------------------------|
| Product | : | Aluminium Silicon Sputtering Target |
| Stock No | : | NS6130-10-1028 |
| Purity | : | >99.9% |
| Molecular Formula | : | AlSi |

Technical Specification

| Diameter | Thickness |
|-------------------|------------------|
| 50.8 mm \pm 1mm | 3 mm \pm 0.5mm |

AlSi sputtering target is a versatile material with unique properties that make it valuable in the production of thin films for a variety of applications in the semiconductor and electronics industries. AlSi sputtering targets are particularly useful in the production of microelectronics and optoelectronics components. They are also used in the production of other electronic components, such as magnetic storage media and sensors.



* This image is for graphic purposes only and does not represent the actual product.

